

1. Record Nr.	UNINA9910698062603321
Titolo	Effect of the evaporation temperature of a tetraphenyl-tetramethyl-trisiloxane (Dow-Corning 704) precursor on the properties of silicon containing diamond-like carbon (Si-DLC) coatings synthesized by ion-beam-assisted deposition (IBAD) [[electronic resource] /] / by C. G. Fountzoulas ... [and others]
Pubbl/distr/stampa	Aberdeen Proving Ground, MD : , : Army Research Laboratory, , [1999]
Descrizione fisica	viii, 14 pages : digital, PDF file
Collana	ARL-TR ; ; 1942
Altri autori (Persone)	Fountzoulas C. G (Constantine G.)
Soggetti	Surfaces (Technology) Silicon Ion implantation Chemical bonds
Lingua di pubblicazione	Inglese
Formato	Materiale a stampa
Livello bibliografico	Monografia
Note generali	Title from title screen (viewed Feb. 26, 2009). "May 1999."
Nota di bibliografia	Includes bibliographical references (page 9).